OIPE	attorney Docke	t No. <u>H1559</u>
1AR 2 4 2004	31	IN THE UNITED STATES PATENT AND TRADEMARK OFFICE
	le patent	application of
BACERIAE	Applicant: Serial No.: Filed: For: Art Unit: Examiner:	Pawloski et al. 10/790,457 March 1, 2004 METHOD FOR REMOVAL OF IMMERSION LITHOGRAPHY MEDIUM IN IMMERSION LITHOGRAPHY PROCESSES Not yet known Not yet known
		INFORMATION DISCLOSURE STATEMENT
	P.O. Box 14	er for Patents 50 VA 22313-1345
	Sir:	
	the patents, listed docum	to 37 C.F.R. 1.97 and 1.98, and in compliance with 37 C.F.R. 1.56, the Office's attention is directed to pending applications, publications and other information listed on the attached PTO-1449. A copy of each ent is enclosed except for: (a) pending applications or (b) those previously cited or submitted to the Office ng application(s) upon which this application relies for an earlier filing date under 35 U.S.C. 120:
	Serial No Filing Da	
	Applicant(s)	ny document, publication or other information for which a date is not given on the attached PTO-1449, believe(s) the same may qualify as "prior" art to this application and should be treated accordingly, plicant(s) reserve(s) the right to contest the prior art status of any document, publication or information, earise.
	this Stateme	ng each listed document that is not in the English language, an English-language translation accompanies and the attached PTO-1449 or a concise explanation of the relevance of the document is the following document(s):
	(a)	Copy of each English language version of a search report indicating the degree of relevance found by the foreign office of each document being submitted from the search report.
	(b)	Attachment entitled "Concise Explanation of Relevance of Non-English Language Documents".
	3. Pursuant	to 37 C.F.R. 1.97(b) this Statement is being filed (one must be checked):
	(a) <u>X</u>	Within 3 months of the filing date, date of entry into the National Stage, or filing date of CPA.
	(b)	Before the mailing date of a first Office Action on the merits. If this Statement is not filed before the mailing date of a first Office Action on the merits, the required certification is given below or, in the absence thereof, the Office is authorized to charge the required fee set forth in 37 C.F.R. 1.17(p) to Deposit Account No. 18-0988 for consideration of this Statement.

(c) ___

Before the mailing date of a first Office Action on the merits after a first or second submission after final rejection under 37 C.F.R. 1.129(a).

(d) After the period set forth in 37 C.F.R. 1.97(b) but before the mailing date of either a final action or a notice of allowance.
(1) The required certification is given below, or
(2) Enclosed is a check covering the fee set forth in 37 C.F.R. 1.17(p) for consideration of this Statement, or
(3) Charge the fee set forth in 37 C.F.R. 1.17(p) to Deposit Account No. 18-0988
(e) After the mailing date of either a final action or a notice of allowance, but before payment of the issue fee. Petition hereby is made for consideration of this Statement and the required certification is indicated below.
(1) Enclosed is a check covering the fee set forth in 37 C.F.R. 1.17(p), or
(2) Charge the fee set forth in 37 C.F.R. 1.17(p) to Deposit Account No. 18-0988.
4. Certification (if applicable)
(a) The undersigned hereby certifies that each item of information contained in this Statement was first cited in any communication from a foreign patent office in a counterpart foreign application not more than 3 months prior to the filing of this Statement.
(b) The undersigned hereby certifies that no item of information contained in this Statement was cited in a communication from a foreign patent office in a counterpart foreign application or, to the undersigned's knowledge after making reasonable inquiry, was known to any individual designated in 37 C.F.R. 1.56(c) more than 3 months prior to the filing of this Statement.
5. The Commissioner is hereby authorized to charge any additional fees or credit any overpayment to Deposit Account No. 18-0988.
Respectfully Submitted,
RENNER, OTTO, BOISSELLE & SKLAR, LLP
By Molland Wang Thomas W. Adams
Reg. No. 35,047 1621 Euclid Avenue, 19th Floor Cleveland, Ohio 44115 (216) 621-1113
CERTIFICATE OF MAILING UNDER 37 C.F.R. §1.8
I hereby certify that this correspondence (along with any paper referenced as being attached or enclosed) is being deposited on the below date with the United States Postal Service with sufficient postage as first class mail in an envelope addressed to Commissioner for Patents, U.S. Patent and Trademark Office, Washington, D.C. 20231.

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Form PTO-1449 (Modified)	Atty Docket No.	Serial No.	
LIST OF PATENTS AND PUBLICATIONS	H1559	10/790,457	
FOR APPLICANT'S INFORMATION DISCLOSURE STATEMENT	Applicant: Pawloski		
MAR 2 1 2004 (Use several sheets if necessary)	Filing Date	Group	
MAR 2 2 2 3 3 3 3 3 3 3 3 3 3 3 3 3 3 3 3	03/01/04		

U.S. PATENT DOCUMENTS

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& TRADE	withEt	U.S. PA	TENT DOCUMENTS			
Examiner Initial	Document Number	Date	Name	Class	Sub- class	Filing Date i Appropriate
	5,610,683	03/11/97	Takahashi	355	53	
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FOREIGN PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Country	Class	Sub- class	Translation	
i iiidai						Yes	No
	0 822 583 A2	04/02/98	EP				
	0 829 312 B1	04/06/03	EP				

OTHER ART

Examiner Initial	Author, Title, Date, Pertinent Pages, etc.		
	Switkes et al.; "Immersion Lithography at 157 nm"; J. Vac. Sci. Technol. B 19(6), Nov./Dec. 2001; pp. 2353-2356.		
	Smith et al.; "Immersion Optical Lithography at 193 nm"; Rochester Institute of Technology; Future Fab Int'l, Vol. 15 (07/11/2003).		
Goldfarb et al.; "Aqueous-based Photoresist Drying Using Supercritical Ca Dioxide to Prevent Pattern Collapse"; J. Vac. Sci. Technol. B 18(6), Nov./D 2000; pp. 3313-3317.			
	Jincao et al.; "Prevention of Photoresist Pattern Collapse by Using Liquid Carbon Dioxide"; Ind. Eng. Chem. Res. 2001, 40, pp. 5858-5860.		
	Sundararajan et al.; "Supercritical CO ₂ Processing for Submicron Imaging of Fluoropolymers"; Chem. Mater, 2000, 12, pp. 41-48.		

XAMINER

DATE CONSIDERED

EXAMINER: MAR 2 4 2004

Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

Information Disclosure Statement PTO-1449 (Modified)

Se identification of any reference is not intended to be, and should not be understood as being, an admission that such publication, in fact, constitutes "prior art within the meaning of applicable law since, for example, a given reference may have a later effective date than first seems apparent or the reference may have a ference is a matter to be resolved during prosecution.

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